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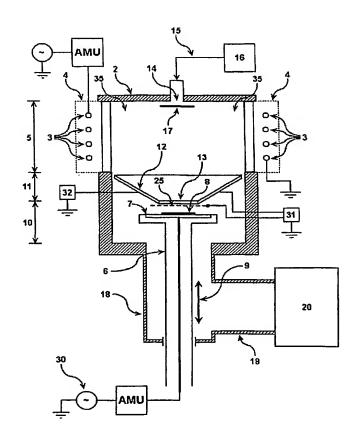
- (71) Applicant (for all designated States except US): OX-FORD INSTRUMENTS PLASMA TECHNOLOGY LIMITED [GB/GB]; Old Station Way, Eynsham, Oxford OX8 1TL (GB).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): COOKE, Michael,

Joseph [GB/GB]; 4 Dean Avenue, Thornbury, Bristol BS35 1JJ (GB). HASSALL, Geoffrey [GB/GB]; Lyndale, Shillingford St. George, Exeter EX2 9QL (GB).

- (74) Agent: GILL JENNINGS & EVERY; Broadgate House, 7 Eldon Street, London EC2M 7LH (GB).
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(54) Title: APPARATUS AND METHOD FOR PLASMA TREATING A SUBSTRATE



(57) Abstract: Apparatus is provided for plasma treating a substrate. This has a chamber (2) and a plasma generator (4) which forms a plasma from one or more gases flowing within the chamber so as to produce one or more species for interacting with a substrate (8) placed within the chamber. A guide (12) is provided for directing the gas flow containing the species towards the substrate (8). When in use, the width of the plasma is greater than that of the substrate by an amount defining an outer region of plasma. The guide is adapted to direct the species from at least substantially all of the outer region of the plasma towards the substrate. A corresponding method of plasma treatment is also disclosed.

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